

amcoss products for substrate processing_

- // Fully-automated single wafer processing equipment amc 1000+, amc 2000+, amc 2500+ for coating, developing, cleaning, lift-off, vapor priming, heating and cooling
- // Semi-automated single wafer processing equipment amr 200 and amr 300 for small-lot production in laboratories, R&D, etc. (coating, developing, cleaning, lift-off, vapor priming, heating and cooling)
- // Spin coating, spray coating
- // Spin developing, spray developing
- // Vapor Priming
- // Wafer cleaning
- // (Laboratory) hotplate/coolplate
- // Development of process modules
- // ams pilot software for process control
- // HMDS batch processing equipment amc hm200
- // Customer-specific equipment
- // Media cabinet
- // amh heat exchanger for temperatures from 30 °C to 95 °C
- // amh chiller for temperatures from 0 °C to 60 °C

